	Application No.	Applicant(s)	
Notice of Allowability	10/804,890 Examiner	LI ET AL.	
•	LXMIIIICI	Alt olin	
	Bernard E. Souw	2881	
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate communication is sufficiently.	his application. If not included ication will be mailed in due course. THIS	ive
1. This communication is responsive to <u>04/07/2005</u> .			
2. The allowed claim(s) is/are <u>1,3-6,11,13,14 and 16-20</u> .			
3. \boxtimes The drawings filed on <u>04/07/2005</u> are accepted by the Example 1.	miner.		
 4. Acknowledgment is made of a claim for foreign priority una) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 	been received. been received in Application	No	
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		reply complying with the requirements	
5. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give			
6. CORRECTED DRAWINGS (as "replacement sheets") mus (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the	on's Patent Drawing Review . s Amendment / Comment or i .84(c)) should be written on the	n the Office action of drawings in the front (not the back) of	
DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT	sit of BIOLOGICAL MATE	RIAL must be submitted. Note the	
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	6. ☐ Interview Sur Paper No./N 7. ☑ Examiner's A	rmal Patent Application (PTO-152) nmary (PTO-413), lail Date mendment/Comment tatement of Reasons for Allowance	

Application/Control Number: 10/804,890 Page 2

Art Unit: 2881

DETAILED ACTION

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this Examiner's Amendment has been given during a phone conversation with applicant's attorney, Mr. Randy W. Tung, Reg. No. 31,311, on June 09, 2005.

- (a) In the claims (as amended on 04/07/2005):
- Cancel claims 9, 12 and 15.
- In claim 1, last line, after "monitored V_E ", delete [.] and insert -- ; --, then add the following paragraphs:
- -- means for calculating an estimated radius $R_{\rm e}$ of ions being implanted by the ion implanter; --
- -- means for determining an offset value between Ram and Re; --
- -- and means for signaling an alarm if the absolute value of the offset, $|R_{am} R_e|$, is larger than a predetermined radius tolerance level L. --

- ▶ In claim 4, lines 1-4, after "of claim 1", prior to ", wherein the means", delete [further comprising: means for calculating an estimated real-time radius R_e of ions being implanted by the ion implanter].
- ▶ In claim 6, lines 13-14, after "and a", prior to "estimated", delete [real-time].
- In claim 6, lines 16-17, after "radius tolerance level L", delete [having the step of].
- In claim 6, lines 24-26, after "monitored V_{E_i} ", prior to "calculating a plurality", delete [and].
- In claim 6, line 28, after "predefined AMUs", prior to " . ", insert -- and signaling an alarm if any of the absolute values of the offset between R_{am} and R_{e} is larger than the predetermined radius tolerance level L --

Applicant's Amendment

2. The Amendment filed 04/07/2005 in response to the office action dated 12/01/2004 has been entered. The present Office Action is made with all the arguments being fully considered.

The specification has been amended.

The drawings (Fig. 2 and Fig.3) have been amended.

Claims 2, 7, 8 and 10 have been cancelled.

New claims 19 and 20 have been added.

Claims 9, 12 and 15 have been cancelled per Examiner's Amendment (see above).

Claims 1, 3-6, 11, 13, 14 and 16-20 remain pending in this office action.

Objection to the Specification Withdrawn

3. The specification having been properly amended, the previous objections are now withdrawn.

§ 112 Rejection Withdrawn

4. The claims having been properly amended, the previous rejections under 35 U.S.C. §112, second paragraph, are now withdrawn.

ALLOWANCE

5. Claims 1, 3-6, 11, 13, 14 and 16-20 are allowed.

The claims are subsequently renumbered to claims 1-13.

Reasons for Allowance

6. The following is an examiner's statement of reasons for allowance:

An ion implanter device or method comprising an analyzing magnet having a radius R_{am} ; means for, or step of, calculating an estimated radius R_e of ions being implanted by the implanter; means for, or step of, calculating an absolute value of the offset between R_e and the analyzing magnet radius R_{am} ; and means for, or step of, signaling an alarm, or stopping the operation of the ion implanter, or recalibrating the ion implanter, in the event the absolute value of the offset between R_e and the analyzing

Art Unit: 2881

magnet radius R_{am} is larger than a predetermined radius of tolerance level L, i.e., in case $|R_{am} - R_e| < L$, as recited in claims 1, 6, 17, 19 and 20, is neither anticipated nor rendered obvious by any prior art.

Claims 3-5, 11, 13, 14 and 16-18 are also allowed because of its/their dependencies, either directly or indirectly, upon the allowed claims 1, 6 or 17.

7. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Relevant Prior Art

8. This prior art made of record and not relied upon is considered pertinent to applicant's disclosure: USPAT # 5,244,820 and USPAT # 5,134,301, both issued to Kamata et al., USPAT 4,899,059 issued to Freytsis et al., USPGPUB 2004/0245476 and USPAGPUB 2004/0188631, both issued to Horsky et al., disclose an ion implantation apparatus facilitated with various means and/or method to prevent undesired ion species from being implanted into the target wafer. However, none of those references recite any means for, or step of, signaling an alarm, or stopping the operation of the ion implanter, or recalibrating the ion implanter, in case the absolute value of the difference between an estimated ion radius R_e and the analyzing magnet

Application/Control Number: 10/804,890

Art Unit: 2881

radius Ram is larger than a predetermined radius of tolerance level L, as claimed in the

Page 6

present invention.

Communications

9. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Bernard E Souw whose telephone number is 571 272

2482. The examiner can normally be reached on Monday thru Friday, 9:00 am to 5:00

pm..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, John R Lee can be reached on 571 272 2477. The central fax phone

number for the organization where this application or proceeding is assigned is (703)

872-9306 for regular communications as well as for After Final communications.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is 703 308

0956.

bes

June 09, 2005

WHN R. LEE

SUPERVISORY PATENT EXAMINER

TECHNOLOGY CENTER 2800